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With the principle of "Quality Parts, Customers Priority, Honest Operation, and Considerate Service", our business mainly focus on the distribution of electronic components. Line cards we deal with include Microchip, ALPS, ROHM, Xilinx, Pulse, ON, Everlight and Freescale. Main products comprise IC, Modules, Potentiometer, IC Socket, Relay, Connector. Our parts cover such applications as commercial, industrial, and automotives areas.

We are looking forward to setting up business relationship with you and hope to provide you with the best service and solution. Let us make a better world for our industry!



Contact us

Tel: +86-755-8981 8866 Fax: +86-755-8427 6832

Email & Skype: info@chipsmall.com Web: www.chipsmall.com

Address: A1208, Overseas Decoration Building, #122 Zhenhua RD., Futian, Shenzhen, China







eGaN® FET DATASHEET EPC2021

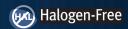
EPC2021 – Enhancement Mode Power Transistor

 \overline{V}_{DSS} , 80 V $R_{DS(on)}$, $2.5~m\Omega$ $\overline{\mathsf{I}_{\mathsf{D}}}$, 90 A









Gallium Nitride is grown on Silicon Wafers and processed using standard CMOS equipment leveraging the infrastructure that has been developed over the last 60 years. GaN's exceptionally $high\ electron\ mobility\ and\ low\ temperature\ coefficient\ allows\ very\ low\ R_{DS(on)},\ while\ its\ lateral\ device$ structure and majority carrier diode provide exceptionally low Q_G and zero Q_{RR} . The end result is a device that can handle tasks where very high switching frequency, and low on-time are beneficial as well as those where on-state losses dominate.

Maximum Ratings					
V _{DS}	Drain-to-Source Voltage (Continuous)	80 V			
• 03	Drain-to-Source Voltage (up to 10,000 5ms pulses at 150°C)	96	·		
I _D	Continuous ($T_A = 25^{\circ}\text{C}$, $R_{0JA} = 3.5^{\circ}\text{C/W}$)	90	Α		
טי	Pulsed (25°C, T _{PULSE} = 300 μs)	420			
V _{GS}	Gate-to-Source Voltage	6	V		
V GS	Gate-to-Source Voltage	-4			
Tj	Operating Temperature	-40 to 150	°C		
T _{STG}	Storage Temperature	-40 to 150			



EPC2021 eGaN® FETs are supplied only in passivated die form with solder bumps. Die Size: 6.05 mm x 2.3 mm

- High Speed DC-DC Conversion
- · Motor Drive
- Industrial Automation
- · Synchronous Rectification
- · Inrush Protection
- · Class-D Audio

www.epc-co.com/epc/Products/eGaNFETs/EPC2021.aspx

	Static Characteristics (T _J = 25°C unless otherwise stated)					
PARAMETER		TEST CONDITIONS MIN		TYP	MAX	UNIT
BV _{DSS} Drain-to-Source Voltage		$V_{GS} = 0 \text{ V, } I_D = 1 \text{ mA}$	80			V
I _{DSS}	Drain Source Leakage	$V_{DS} = 64 \text{ V}, V_{GS} = 0 \text{ V}$		0.1	0.7	mA
,	Gate-to-Source Forward Leakage	$V_{GS} = 5 \text{ V}$		1	9	mA
I _{GSS}	Gate-to-Source Reverse Leakage	$V_{GS} = -4 V$		0.1	0.7	mA
$V_{GS(TH)}$	Gate Threshold Voltage	$V_{DS} = V_{GS}$, $I_D = 14 \text{ mA}$	0.8	1.4	2.5	V
R _{DS(on)}	Drain-to-Source On Resistance	$V_{GS} = 5 \text{ V}, I_D = 29 \text{ A}$		1.8	2.5	mΩ
V_{SD}	Source-to-Drain Forward Voltage	$I_S = 0.5 \text{ A}, V_{GS} = 0 \text{ V}$		1.6		V

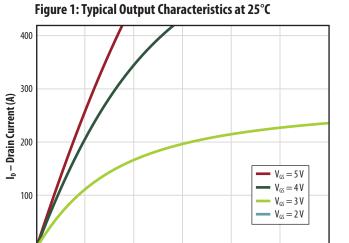
All measurements were done with substrate shorted to source.

Thermal Characteristics					
		TYP	UNIT		
$R_{\theta JC}$	Thermal Resistance, Junction to Case	0.4	°C/W		
$R_{\theta JB}$	Thermal Resistance, Junction to Board	1.1	°C/W		
$R_{\theta JA}$	Thermal Resistance, Junction to Ambient (Note 1)	42	°C/W		

Note 1: $R_{\text{\tiny BJA}}$ is determined with the device mounted on one square inch of copper pad, single layer 2 oz copper on FR4 board. $See \ http://epc-co.com/epc/documents/product-training/Appnote_Thermal_Performance_of_eGaN_FETs.pdf for \ details.$ eGaN® FET DATASHEET EPC2021

Dynamic Characteristics (T _J = 25°C unless otherwise stated)						
PARAMETER		TEST CONDITIONS	MIN	ТҮР	MAX	UNIT
C _{ISS}	Input Capacitance			1650	1980	
C _{RSS}	Reverse Transfer Capacitance	$V_{DS} = 40 \text{ V}, V_{GS} = 0 \text{ V}$		20		
C _{oss}	Output Capacitance			970	1460	рF
C _{OSS(ER)}	Effective Output Capacitance, Enegy Related (Note 2)	$V_{DS} = 0 \text{ to } 40 \text{ V}, V_{GS} = 0 \text{ V}$		1090		pr
C _{OSS(TR)}	Effective Output Capacitance, Time Related (Note 3)			1310		
R_{G}	Gate Resistance			0.3		Ω
Q_{G}	Total Gate Charge	$V_{DS} = 40 \text{ V}, V_{GS} = 5 \text{ V}, I_{D} = 29 \text{ A}$		15	19	
Q _{GS}	Gate-to-Source Charge			3.4		
Q_{GD}	Gate-to-Drain Charge	$V_{DS} = 40 \text{ V}, I_{D} = 29 \text{ A}$		2.3		nC
Q _{G(TH)}	Gate Charge at Threshold			2.5		l lic
Qoss	Output Charge	$V_{DS} = 40 \text{ V}, V_{GS} = 0 \text{ V}$		63	95	
Q_{RR}	Source-to-Drain Recovery Charge			0		

Note 2: $C_{OSS(RN)}$ is a fixed capacitance that gives the same stored energy as C_{OSS} while V_{DS} is rising from 0 to 50% BVDSS. Note 3: $C_{OSS(RN)}$ is a fixed capacitance that gives the same charging time as C_{OSS} while V_{DS} is rising from 0 to 50% BVDSS.



1.5

V_{DS} – Drain-to-Source Voltage (V)

400 25°C

Figure 2: Transfer Characteristics

I_D – Drain Current (A) 125°C 200 $V_{DS} = 3 V$ 100 0.5 1.0 3.0 3.5 4.5 5.0 V_{GS} – Gate-to-Source Voltage (V)

Figure 3: $R_{DS(on)}$ vs. V_{GS} for Various Drain Currents

0.5

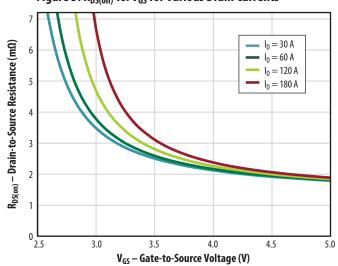
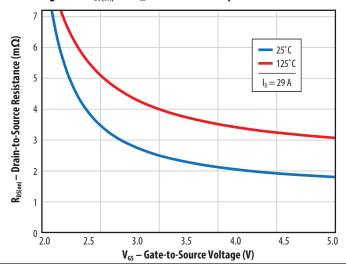


Figure 4: R_{DS(on)} vs. V_{GS} for Various Temperatures



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Figure 5a: Capacitance (Linear Scale)

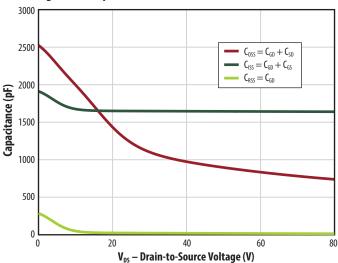


Figure 5b: Capacitance (Log Scale)

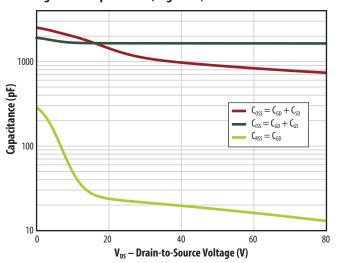


Figure 6: Gate Charge

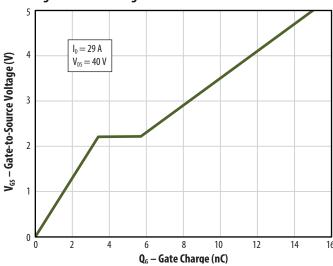


Figure 7: Reverse Drain-Source Characteristics

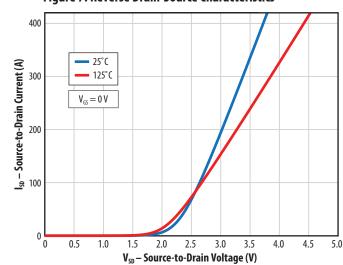


Figure 8: Normalized On-State Resistance vs. Temperature

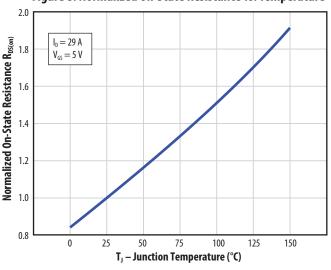
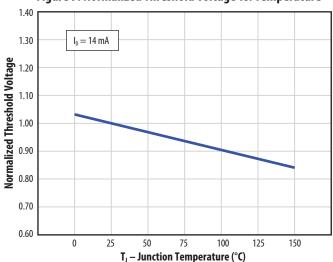
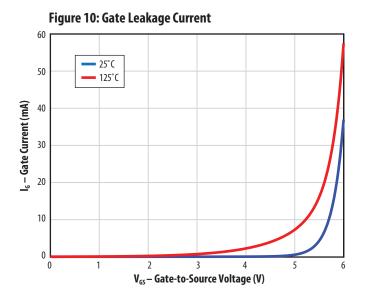


Figure 9: Normalized Threshold Voltage vs. Temperature



All measurements were done with substrate shortened to source

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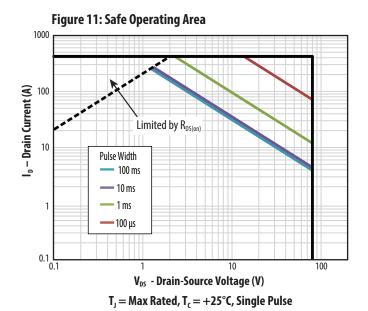
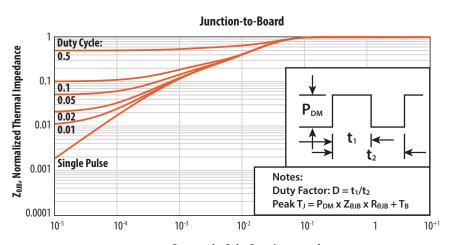
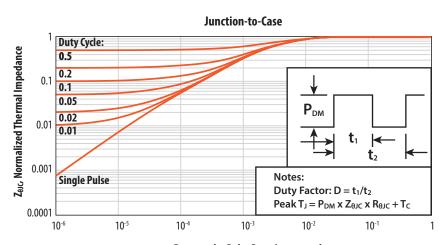


Figure 12: Transient Thermal Response Curves



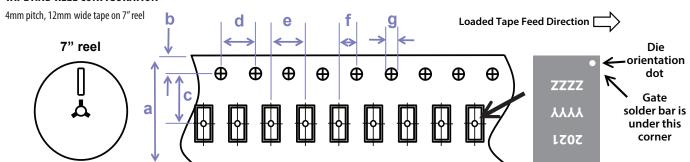
tp, Rectangular Pulse Duration, seconds



t_p, Rectangular Pulse Duration, seconds

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TAPE AND REEL CONFIGURATION



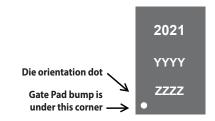
	EPC2021 (note 1)		
Dimension (mm)	n (mm) target min max		
а	12.00	11.70	12.30
b	1.75	1.65	1.85
c (see note)	5.50	5.45	5.55
d	4.00	3.90	4.10
е	4.00	3.90	4.10
f (see note)	2.00	1.95	2.05
g	1.50	1.50	1.60

Die is placed into pocket solder bar side down (face side down)

Note 1: MSL 1 (moisture sensitivity level 1) classified according to IPC/JEDEC industry standard.

Note 2: Pocket position is relative to the sprocket hole measured as true position of the pocket, not the pocket hole.

DIE MARKINGS

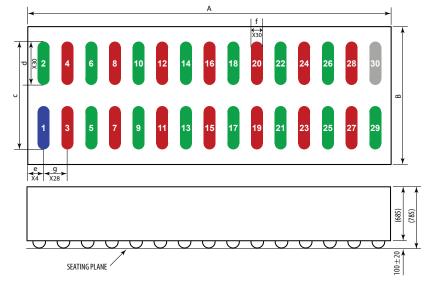


	Part	Laser Marking			
	Number	Part # Marking Line 1	Lot_Date Code Marking Line 2	Lot_Date Code Marking Line 3	
ĺ	EPC2021	2021	YYYY	ZZZZ	

DIE OUTLINE

Side View

Solder Bump View



	Micrometers					
DIM	MIN Nominal MAX					
Α	6020	6050	6080			
В	2270	2300	2330			
c	2047	2050	2053			
d	717	720	723			
е	210	225	240			
f	195	200	205			
g	400	400	400			

Pad 1 is Gate

Pads 2,5,6,9,10,13,14,17,18,21,22,

25,26,29 are Source

Pads 3,4,7,8,11,12,15,16,19,20,23,

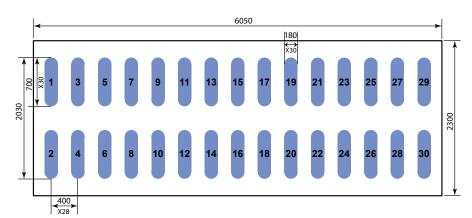
24,27,28 are Drain

Pad 30 is Substrate

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RECOMMENDED LAND PATTERN

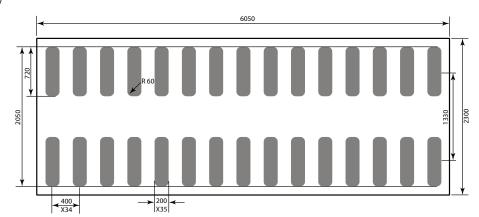
(units in µm)



Land pattern is solder mask defined Solder mask opening is 180 μm It is recommended to have on-Cu trace **PCB** vias

RECOMMENDED **STENCIL DRAWING**

(units in µm)



Recommended stencil should be 4 mil (100 µm) thick, must be laser cut, openings per drawing.

Intended for use with SAC305 Type 3 solder, reference 88.5% metals content.

Additional assembly resources available at http://epc-co.com/epc/DesignSupport/ AssemblyBasics.aspx

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U.S. Patents 8,350,294; 8,404,508; 8,431,960; 8,436,398; 8,785,974; 8,890,168; 8,969,918; 8,853,749; 8,823,012

Information subject to change without notice. Revised April, 2016